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APPLICATION NO. FILING DATE		FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO	
09/847,658	05/02/2001	Wolfgang Singer	82704 7054		
75	590 06/24/2003				
Gerald T. Shekleton, Esq.			EXAMINER		
Welsh & Katz, Ltd. 120 S. Riverside Plaza, 22nd Floor			CHOI, WILLIAM C		
Chicago, IL 60606			ART UNIT	PAPER NUMBER	
			2873		

DATE MAILED: 06/24/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

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			Application	No.	Applicant(s)	
	A1 - 4: -	a.e. A.llannahilita	09/847,658		SINGER ET AL.	
	NOTIC	of Allowability	Examiner		Art Unit	
			William C. C	hoi	2873	
All claims bein herewith (or pr NOTICE OF A	g allowable eviously ma LLOWABIL	IG DATE of this communication, PROSECUTION ON THE MER ailed), a Notice of Allowance (PTO LITY IS NOT A GRANT OF PATE on by the applicant. See 37 CFR	ITS IS (OR REMAIN OL-85) or other appro	S) CLOSED in this appopriate communication application is subject to	plication. If not includ will be mailed in due	ed course. THIS
		n is responsive to <u>Amendment C</u>				
		s) is/are <u>1-3,7,19-25,27-32 and 3</u> on <u>02 May 2001 and 07 April 20</u> 0		ne Evaminer		
=	vledgment is	s made of a claim for foreign prior Some* c) \[\sum \text{None} \text{None} \]				
1	. 🛛 Certifie	ed copies of the priority document	ts have been receive	d.		
2	. 🔲 Certifie	d copies of the priority document	ts have been receive	d in Application No	·	
3	. Copies	of the certified copies of the prior	rity documents have	been received in this	national stage applica	ation from the
	Inte	rnational Bureau (PCT Rule 17.2	(a)).			
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	_	made of a claim for domestic pri	•	·	onal application).	
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b. Mcknow	leagment is	made of a claim for domestic pri	ority under 35 U.S.C	. 99 120 and/or 121.		
Applicant has below. Failure	THREE MO	NTHS FROM THE "MAILING DA	ATE" of this commun ENT of this applicatio	ication to file a reply con. THIS THREE-MOI	omplying with the requ	uirements noted EXTENDABLE.
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3 Notice of 6 Noti	Draftperson on Disclosur	Cited (PTO-892) 's Patent Drawing Review (PTO- e Statements (PTO-1449), Paper Regarding Requirement for Dep	r No	4☐ Interview Summ 6⊠ Examiner's Ame 8⊠ Examiner's State 9☐ Other Second 100	al Patent Application ary (PTO-413), Pape endment/Comment ement of Reasons for	r No

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Application/Control Number: 09/847,658

Art Unit: 2873

EXAMINER'S AMENDMENT

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Gerald Shekleton on 6/19/2003.

The application has been amended as follows:

1. Claim 36, line 3, after "claim" delete "26" and insert --20--.

Allowed Claims: 1-3, 7, 19-25, 27-32 and 34-42.

REASONS FOR ALLOWANCE

The following is an examiner's statement of reasons for allowance: none of the prior art either alone or in combination disclose or teach of the claimed combination of limitations to warrant a rejection under 35 USC 102 or 103. Specifically, with respect to independent claim 1, none of the prior art alone or in combination disclose or teach of a projection lens as claimed, specifically wherein the gas chamber is constructed as an at least approximately plane-parallel manipulation chamber located between the lens arrangement and the image plane.

Specifically, with respect to independent claim 2, none of the prior art alone or in combination disclose or teach of a projection lens as claimed, specifically wherein the

Application/Control Number: 09/847,658

Art Unit: 2873

gas chamber is constructed as an at least approximately plane-parallel manipulation chamber located between the lens arrangement and the image plane.

Specifically, with respect to independent claim 3, none of the prior art alone or in combination disclose or teach of a projection lens as claimed, specifically wherein the gas chamber is constructed as an at least approximately plane-parallel manipulation chamber located between the lens arrangement and the image plane.

Specifically, with respect to independent claim 19, none of the prior art alone or in combination disclose or teach of a system for projection lens as claimed, specifically wherein the gas chamber is a manipulation chamber formed between adjacent planeparallel optical elements.

Specifically, with respect to independent claim 20, none of the prior art alone or in combination disclose or teach of a system for projection lens as claimed, specifically including an at least approximately plane-parallel manipulable gas interspace, for the purpose of removing field curvature, on a substrate, which is to be exposed, in a sixth optical group.

Specifically, with respect to independent claim 21, none of the prior art alone or in combination disclose or teach of a system for projection lens as claimed, specifically wherein the gas chamber is constructed between adjacent approximately plane-parallel optical elements to form a manipulation chamber.

Specifically, with respect to independent claim 29, none of the prior art alone or in combination disclose or teach of a method for producing microstructured components

Application/Control Number: 09/847,658

Art Unit: 2873

as claimed, specifically wherein the refractive index is manipulated by pressure changes and changes in gas composition.

Specifically, with respect to independent claim 37, none of the prior art alone or in combination disclose or teach of a projection lens for microlithography as claimed, specifically wherein the gas chamber is a manipulation chamber formed between adjacent plane-parallel optical elements.

Specifically, with respect to independent claim 38, none of the prior art alone or in combination disclose or teach of a projection lens for microlithography as claimed, specifically wherein the gas chamber is constructed between adjacent plane-parallel optical elements to form a manipulation chamber.

Specifically, with respect to independent claim 39, none of the prior art alone or in combination disclose or teach of a projection lens for microlithography as claimed, specifically wherein the gas chamber is constructed between adjacent approximately plane-parallel optical elements to form a manipulation chamber.

Specifically, with respect to independent claim 40, none of the prior art alone or in combination disclose or teach of a projection lens as claimed, specifically wherein the gas chamber is located between an end plate and the lens situated adjacent to the end plate.

Specifically, with respect to independent claim 41, none of the prior art alone or in combination disclose or teach of a projection lens as claimed, specifically wherein the gas chamber is located between an end plate and the lens situated adjacent to the end plate.

Specifically, with respect to independent claim 42, none of the prior art alone or in combination disclose or teach of a projection lens as claimed, specifically wherein the gas chamber is located between an end plate and the lens situated adjacent to the end plate.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

CONCLUSION

Any inquiry concerning this communication or earlier communications from the examiner should be directed to William C. Choi whose telephone number is (703) 305-3100. The examiner can normally be reached on Monday-Friday from about 9:00 am to 6 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Georgia Y. Epps can be reached on (703) 308-4883. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 305-3431 for regular communications and (703) 305-3432 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

W.C.

William Choi **Patent Examiner** Art Unit 2873 June 19, 2003

Georgia Epps
Supervisory Patent Examiner
Technology Center 2800